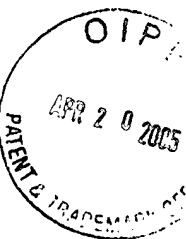


PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE



Application No. : 10/696,432 Confirmation No. 6825
Applicant : Ying-Lang Wang
Filed : October 29, 2003
TC/A.U. : 2813

Title : CMP Process Leaving No Residual Oxide Layer or Slurry
Particles

Docket No. : N1085-90131 (TS01-167CB)
Customer No. : 08933

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

**CERTIFICATE OF MAILING,
37 C.F.R. §1.8(a)**

I certify that this correspondence and the
enclosures mentioned therein are being deposited
by First Class U.S. Mail with sufficient postage on
the date shown below, addressed to Commissioner
for Patents, PO Box 1450, Alexandria, Virginia
22313-1450.

Richard A. Paikoff
Richard A. Paikoff, Reg. No. 34,892

11-2-05
Date

AMENDMENT AND RESPONSE

Sir:

In response to the Office Action of December 28, 2004, please amend the above-
identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2
of this paper.

Remarks begin on page 4 of this paper.